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APPLICATION NO.	Fil	LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/389,393	393 09/03/1999		HISASHI OHTANI	07977/204002	5375
26171	7590	02/02/2006		EXAMINER	
FISH & RI	CHARDS	ON P.C.	JACKSON JR, JEROME		
P.O. BOX 1 MINNEAPO		55440-1022		ART UNIT	PAPER NUMBER
	•			2815	
				DATE MAILED: 02/02/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

		86
	Application No.	Applicant(s)
	09/389,393	OHTANI, HISASHI
Office Action Summary	Examiner	Art Unit
	Jerome Jackson Jr.	2815
The MAILING DATE of this communication ap	ppears on the cover sheet wi	th the correspondence address
Period for Reply A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING I. - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period. - Failure to reply within the set or extended period for reply will, by statu Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNION (136(a). In no event, however, may a red will apply and will expire SIX (6) MON te, cause the application to become AB	CATION. eply be timely filed THS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).
Status		
_	Marra mah a m 0005	
1) Responsive to communication(s) filed on 28/		
2a) ☐ This action is FINAL . 2b) ☐ Th 3) ☐ Since this application is in condition for allows	is action is non-final.	ers prosecution as to the merits is
closed in accordance with the practice under		
Disposition of Claims		
4)	awn from consideration. 5,78-81 and 84-92 is/are rej	
Application Papers		
9)☐ The specification is objected to by the Examir		•
10) ☐ The drawing(s) filed on is/are: a) ☐ ac	cepted or b) objected to	by the Examiner.
Applicant may not request that any objection to the	• • • • • • • • • • • • • • • • • • • •	
Replacement drawing sheet(s) including the corre		
11) The oath or declaration is objected to by the E	Examiner. Note the attached	1 Office Action or form P1O-152.
Priority under 35 U.S.C. § 119	•	
12) Acknowledgment is made of a claim for foreig a) All b) Some * c) None of: 1. Certified copies of the priority documer 2. Certified copies of the priority documer 3. Copies of the certified copies of the pri application from the International Burer * See the attached detailed Office action for a list	nts have been received. nts have been received in A ority documents have been au (PCT Rule 17.2(a)).	pplication No received in this National Stage
Attachment(s)		
1) Notice of References Cited (PTO-892)		Summary (PTO-413)
 Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08 Paper No(s)/Mail Date 		s)/Mail Date nformal Patent Application (PTO-152)

Art Unit: 2815

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1,44,45,48,55-57,60-63,66-69,72-75,78-81, and 84-92 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ha '234 in view of Yamazaki '019.

Ha shows the dual layer gate structure with Idd regions. The top gate layer is wider than the bottom gate layer. The difference between Ha and the claims is the overlap of the s/d metallization with another gate structure. This difference is not patentable as Yamazaki suggests such overlap structure as ordinary and compact design for matrix displays. See figure 16E or 17E for example. Other claims reciting various gate metals and insulation layers are obvious as the prior art applied likewise teaches anodizable metals such as chromium and aluminum, and oxide or nitride insulation layers.

Applicant's arguments with respect to all the claims have been considered but are most in view of the new ground(s) of rejection.

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within

TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jerome Jackson Jr. whose telephone number is 571-272-1730. The examiner can normally be reached on M-Th.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas can be reached on 571-272-1664. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

jj

JEROME JACKSON PRIMARY EXAMINER

Page 3